PATENT Reply under 37 C.F., § 1.116 Expedited Procedure Technology Center 1762 Attorney Docket No. 037768-0173

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

First Named Inventor:) Attorney Docket No. 037768-0173
Tapesh YADAV	Group Art Unit: 1762
Application No.: 10/698,564	Examiner: Elena TSOY
Filed: 10-31-2003	Confirmation No. 1121

Title: High volume manufacturing of nanoparticles and nano-dispersed particles at low cost

MS AF

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

I. Amendment After Final Rejection

This paper responds under 37 C.F.R. § 1.116 to the outstanding final Office action dated 06-09-2008. It is timely as it is filed within the shortened statutory period for reply ending 09-09-2008.

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